



ENGINEERING & SCHEMATICS TUFs

Instrumentation, Electrical & P&ID Combined Meeting

The PP&M Global Technical Users Forum chairmen and Intergraph® invite you to attend the SmartPlant® Instrumentation, Electrical, and P&ID Global TUF meetings. Attendees will meet in a combined session before breaking into subject-area meetings in the afternoon. The meeting is open to all current users of SmartPlant Instrumentation, SmartPlant Electrical, and SmartPlant P&ID. The global TUF meeting's objective is for the members of the instrumentation, electrical, and process design communities and users of SmartPlant Instrumentation, SmartPlant Electrical, and SmartPlant P&ID to gather and discuss issues of interest, as well as to provide Intergraph with feedback from the customer community on its needs. Intergraph will also present short- and medium-term software development plans to the user communities.

PP&M ENGINEERING & DESIGN COMBINED TUF		
TIME	Topic/Discussion Leader	ROOM: MARCO POLO 706/707
08:00am	Opening Remarks of the Schematics and 3D-Visualization TUF Chairs	
08:10am	Update on HEXAGON PPM Engineering & Design Tools Organization	
08:30am	HEXAGON PPM Introduction to Smart Completions	
08:45am	Split to the E&S Combined Session and the 3D-Visualization Session	

INSTRUMENTATION, ELECTRICAL & P&ID COMBINED TUF		
TIME	Topic/Discussion Leader ROOM: MARCO POLO 706/707	
08:50am	Opening Remarks and Introductions - (TUF Chairs)	
09:00am	Overview of E&S Tools Products (Frank Joop, Hexagon PPM)	
09:20am	CR Ranking Website Update (Dennis Cooley, Cooleycore)	
09:40am	Data-Centric Engineering (John Dressel, Fluor)	
10:00am	Break/Networking	
10:30am	Hexagon's role in Plant Digitalization (Frank Joop , Hexagon PPM)	
10:50am	Changing the Future with Web APIs (David Kaiser , Hexagon PPM)	
11:10am	The Argo Visualization Project (Tom Szoka , Hexagon PPM)	
11:30am	Harmonization of the User Experience (Frank Joop , Hexagon PPM)	
12:00pm	TUF Luncheon at the Venetian Ballroom C/D (2 nd Level of the Convention Center)	
01:00pm	Instrumentation, Electrical & Process Design Breakout Meetings	